Ref #	Hits	Search Query	DBs	Default Operator	Plurals	Time Stamp
L10	56	((beam or cantilever or membrane) near10 trench near10 substrate) and (sacrificial)	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/04/29 22:57
L11	18	((beam or cantilever or membrane) near10 trench near10 substrate).clm. and (sacrificial)	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/04/29 22:57
L12	5	((beam or cantilever or membrane) near10 trench near10 substrate).clm. and (sacrificial). clm.	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/04/29 22:57
L13	3	((beam or cantilever or membrane) near10 trench near10 substrate).clm. and (sacrificial adj layer).clm.	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/04/29 23:00
114	20	((beam or cantilever or membrane) near10 trench near10 sacrificial)	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/04/29 23:00
L15		((beam or cantilever or membrane) near10 trench near10 sacrificial).clm.	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/04/29 23:02
L16	531	((beam or cantilever or membrane) near10 contact near10 (circuit or circuitry)).clm.	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/04/29 23:03
L17	0	((beam or cantilever or membrane) near10 contact near10 (circuit or circuitry) near10 trench).clm.	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/04/29 23:03
L18	2	((beam or cantilever or membrane) near10 contact near10 (circuit or circuitry) near10 trench)	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/04/29 23:03

L19	70	((beam or cantilever or membrane) near10 contact near10 trench)	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/04/29 23:04
L20	17	((beam or cantilever or membrane) near10 contact near10 trench).clm.	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/04/29 23:05
L21	2	((beam or cantilever or membrane) near10 contact near10 trench near10 (circuit or circuitry))	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/04/29 23:05
L22	5	((beam or cantilever or membrane) with contact near10 trench near10 (circuit or circuitry))	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/04/29 23:05
L23	6	((beam or cantilever or membrane) with contact with trench near10 (circuit or circuitry))	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/04/29 23:05
L24	6	((beam or cantilever or membrane) with contact with trench with (circuit or circuitry))	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/04/29 23:09

Ref #	Hits	Search Query	DBs	Default Operator	Plurals	Time Stamp
L26	0	(beam or cantilever or membrane) with trench with (detect or detecting or detected or detection) with contact with wall	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/04/29 23:20
L27	13	(beam or cantilever or membrane) with trench with contact with wall	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/04/29 23:21
L28	11	(beam or cantilever or membrane) with trench with (detect or detecting or detected or detection or sensing or sensor) with contact	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/04/29 23:21
L29	8	(beam or cantilever or membrane) near10 trench with (detect or detecting or detected or detection or sensing or sensor) with contact	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/04/29 23:21
L30	7	(beam or cantilever or membrane) near10 trench near10 (detect or detecting or detected or detection or sensing or sensor) with contact	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/04/29 23:21
L31	5	(beam or cantilever or membrane) near10 trench near10 (detect or detecting or detected or detection or sensing or sensor) near10 contact	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/04/29 23:21